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CALCULATIONS CONCERNING ELECTRICAL
BREAKDOWN INDUCED BY THE MELTING
OF MICROSCOPIC PROJECTIONS

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REPORT R-280

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Introduction

During the last several years, the understanding of the phenomenon of electrical breakdown in vacuum has been greatly advanced. It is now generally recognized that electrical breakdown between electrodes in a clean environment is initiated by field emission currents drawn from submicroscopic projections on the cathode surface,¹ the electric field at these projections being greatly enhanced from that of the average electric field which would exist in the absence of such projections. Although field emission processes were recognized early as possible mechanisms for the initiation of electrical breakdown,² quantitative identification was not firmly established until the investigations of Dyke,³ and then only for the particular case of the point-to-plane geometry of the Müller⁴ field emission microscope. For this geometry Dyke and his co-workers clearly demonstrated that electrical breakdown was initiated by field emission currents when the current density from the point tungsten cathode exceeded a critical value of 10^8 a/cm². The electric field strengths necessary to draw these current densities are of the order of $5-7 \times 10^7$ v/cm.⁵

Despite their definitive quality, Dyke's results did not seem consistent with results obtained with other electrode geometries. In particular, for broad area parallel electrodes the experimentally obtained electric field strengths were of the order of 10^5 v/cm,¹ two orders of magnitude lower than those found by Dyke. In addition, the electric field strengths at breakdown depended on gap spacing,⁶ a fact at variance to any conceived mechanism involving field emission. With

these apparent discrepancies to a field emission theory of breakdown a plethora of other theories were advanced both before and after Dyke's startling results.¹

Reporting in 1962, Alpert and Lee⁷ analyzed the experimental results of Boyle, Kisliuk and Germer,⁸ who used crossed tungsten wires at short gap spacings, and the results of Dyke and showed a previously unrecognized agreement between these two investigations: electrical breakdown occurred when the electrical field measured at the field emission sites exceeded the critical value of 6.5×10^7 v/cm to within a small experimental error. These findings were greatly extended with the experimental work of Alpert, Lee, Lyman and Tomaschke.¹ Using broad area electrodes they verified the critical field criterion for gap spacings up to 6 mm and voltages up to 250 kv. A similar analysis when applied to the results of Pivovar and Gordienko⁹ and Ahern² and Chambers¹⁰ showed substantial agreement for a constant field criterion for electrical breakdown.

An essential feature of this breakdown criterion is the existence of submicroscopic projections on the surface of the cathode. It has long been recognized that such projections can provide field enhancements of up to several thousand times the field in the absence of the projections.¹¹ Indirect experimental evidence for the existence of such points was provided by Boyle, Kisliuk and Germer.⁸ They observed that the field enhancements necessary to bring their field emission current results into agreement with the Fowler-Nordheim theory were gap dependent. At small gaps approaching a few wave lengths of

light they observed that the field enhancement approached one. From this gap dependence they inferred the existence of points rather than the alternative explanation of exceedingly low work functions.¹² Tomaschke,¹³ using an electron microscope and suitable small but nevertheless broad area tungsten electrodes was able to directly observe the existence of projections on the electrode surface, identify the prebreakdown emission as field emission, and establish that the critical field criterion was applicable. Independently, Little and Whitney¹⁴ for a variety of materials observed in situ that the prebreakdown emission occurred from submicroscopic projections averaging two microns in length. Both experimenters verified that every electrical breakdown resulted in the removal of one or more emission sites.

Subsequently other investigators identified the existence of projections on the surface of the cathode. In particular, Brodie and Weissman¹⁵ using a cylindrical field emission microscope were able to infer the existence of projections by an analysis of the shapes of the field emission patterns. Pivovar and Gordienko⁹ by direct observation, apparently with an electron microscope, were able to demonstrate the existence of projections roughly two microns long on the molybdenum cathodes of their electrodes. The number of projections on broad area electrodes has been observed to be of the order of 50 to 100 per square centimeter by the aforementioned investigators and by Singer and Doolittle¹⁶ using pin-hole x-ray camera equipment.

At present the circumstances of production of projections on the surface of the electrodes has not been fully investigated.

However, certain processes which result in the production of projections have been isolated. Without question the machining and handling of the electrodes before insertion into the vacuum system accounts for many projections. Additionally, Tomaschke¹³ has noted several methods for producing projections prior to and during electrical breakdown. Brodie¹⁷ has witnessed apparent whisker growth by the deposition of impurity materials from an auxiliary thermionic emitter. Pivovar and Gordienko⁹ have noted a particularly unusual case of the production of whiskers in an electrical breakdown experiment. During the process of thoroughly outgassing their molybdenum electrodes at 2000°C, they subsequently found that a profusion of very sharp projections had been formed. An analysis of their data indicates that these whiskers enhanced the electric field by as much as 100 to 4000 times. It seems reasonable that these whiskers grew in the interval immediately after outgassing when the thermal stresses were large, and the substrate warm.

Thus the constant field criterion for electrical breakdown is firmly established. It seems apparent that electrical breakdown for clean tungsten electrodes in an ultrahigh vacuum environment is a field-emission-initiated phenomenon where the emission occurs from submicroscopic projections on the surface of the cathode. At breakdown the locally enhanced field at these projections is a constant to within experimental error as determined from the breakdown voltage and an analysis of the prebreakdown voltage-current relationship. This critical value of electric field is 6.5×10^7 v/cm for tungsten independent of the total voltage between the electrodes or of the macrogeometry of

the electrode surfaces. The results of four independent investigators are summarized in Figure 1. These results demonstrate that when properly analyzed electrical breakdown occurs at constant electric field for the nearly five orders of magnitude of electrode spacing investigated.

Transition Mechanism: Cathodic or Anodic?

The criterion that breakdown will ensue whenever the electric field at the surface of a cathode projection exceeds a critical value seems of technological interest rather than a fundamental result in the sense that it does not directly identify the initiatory event at which the transition to breakdown current occurs. It was recognized that this criterion could not of itself be used to exclude the anode from playing a role in the initiatory event.⁷ However, the agreement in the experimental results summarized in Figure 1 is in itself a persuasive argument that the cathode is the initiatory surface. These results clearly indicate that the breakdown field is independent of all geometrical considerations. Geometries in which the role of the anode is clearly excluded, as in the point-to-plane investigations of Dyke,³ have the same breakdown field as the broad-area, short-gap electrode investigations in which the role of the anode cannot be obviously dismissed. From these considerations alone it seems plausible to assume that the cathode surface is indeed the initiatory surface.

There is additional indirect evidence which supports the contention that the cathode surface is the initiatory surface. Tomaschke,¹³ and independently Little and Whitney,¹⁴ as well as

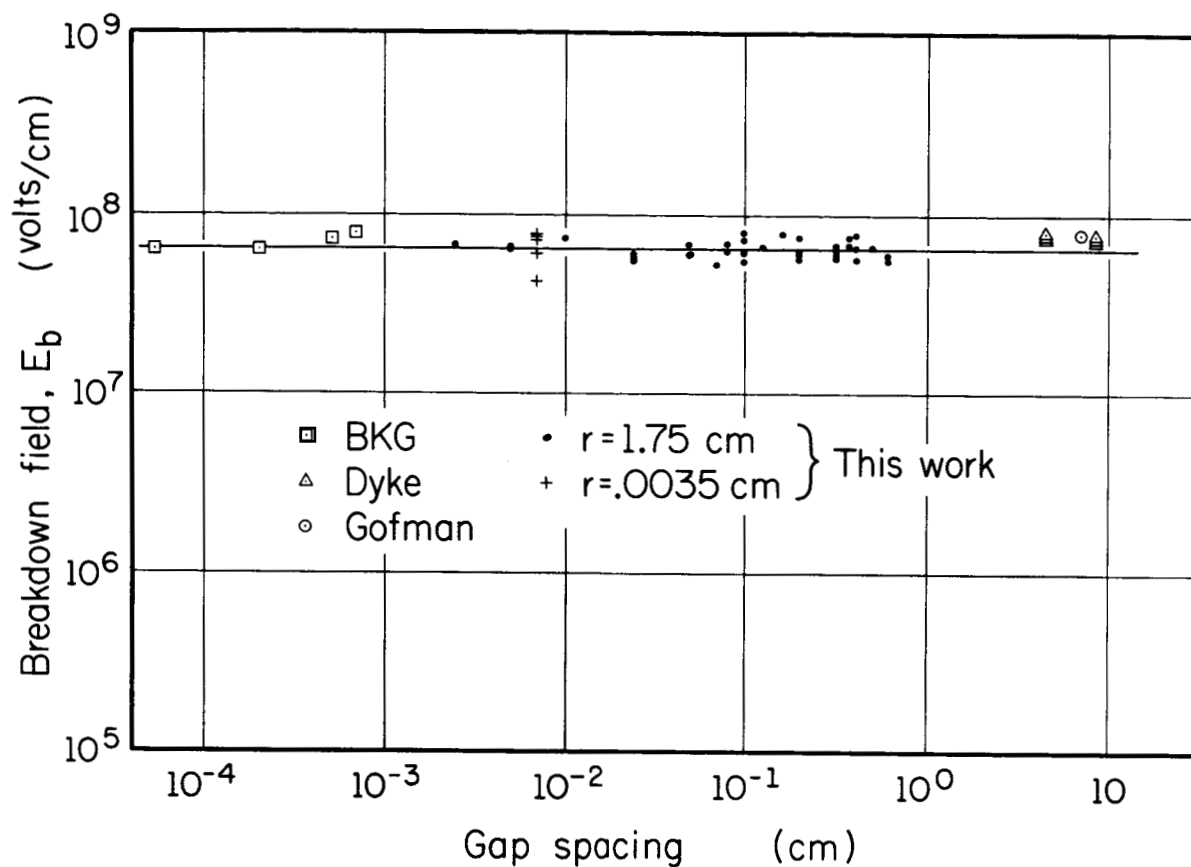


Figure 1. Summary of the Results of Four Independent Investigators for Local Electric Field at Breakdown.

Brodie,¹⁷ find that, coincident with electrical breakdown, one or more emission sites is always destroyed. The conclusion that the cathode surface is the initiatory surface is also consistent with the experimental findings of Pivovar and Gordienko.⁹ In their experiments they found that imposing a transverse magnetic field sufficiently strong to prevent the field emission current from striking the anode surface did not materially improve the voltage-holding capabilities of the electrodes. Finally, in a recent paper by Brodie,¹⁷ it is shown that for nickel the cathode marks which result from the breakdown process are nearly identical, independent of electrode geometry. The cathode marks found on a nickel wire cathode of a cylindrical field emission microscope were indistinguishable from the cathode marks found on a nickel broad area cathode.

But even for larger gap spacings up to 6 mm, where field emission techniques have been used for broad area electrodes, the experimental results tend to support a field emission mechanism. For such gaps, it is found that the voltage-holding capability increases and the background current decreases when a gas is introduced¹⁸ into the gap spacing at a pressure of the order of 10^{-4} Torr. The only plausible explanation thus far presented for this effect is associated with the selective destruction of cathode projections by ion bombardment. Similarly, the experimental results of Murray¹⁹ using hot glass cathodes and Rohrbach²⁰ and Jeydnck²¹ using coated cathodes (coated with high dielectrics to reduce the cathode fields) to obtain higher breakdown voltages are consistent with a cathode-initiating event.

We are not aware of experimental results which support the contention that the anode is involved in the breakdown transition to high currents. No process has been postulated which can generate ions in sufficient numbers to directly increase the interelectrode current by the orders of magnitude necessary in the transition.²² For some experiments, transition time consideration would seem to prevent the anode from even augmenting the field emission current through any known space charge mechanism.²³ Particularly the calculations of Kisliuk²⁴ indicate that the increase in field emission current due to the close approach of single ions to the cathode surface is especially small for large gaps. Mechanisms involving the vaporization of the anode material²⁵ by field emission currents followed by gas breakdown in the vapor do not seem plausible. Experiments in electron beam welding²⁶ indicate that electron beams may have penetration depths orders of magnitude longer than those predicted by Waddington's law²⁷ for single electrons. These experimental results bring into serious question the validity of the calculations of the amount of gas vapor evaporated from the anode. Additionally, no secondary effects of this gas cloud, such as the condensation of the vapor on other surfaces, have been noted in the literature.

In summary, there seems to be strong evidence that the cathode is the initiatory surface, and conversely, little evidence that would demand or even allow the anode to take part in the transition to breakdown.

A Review of Cathode Transition Mechanisms

From their results in the point-to-plane geometry, Dolan, Dyke and Trolan²⁸ calculated that the field emission current densities just prior to breakdown were sufficient to melt the cathode projection. Dyke,³ et al., proposed a regeneration scheme whereby the cathode current is greatly increased through the creation of positive ions by electron impact processes in the metallic vapor evaporated at these elevated temperatures. It does not seem reasonable that this process could be a general process applying to all materials. Not only is there no discontinuity in the vapor pressure at the melting point, but there are orders of magnitude difference in the vapor pressures of common materials at their melting points.²⁹ Furthermore, the experiments of Gorkov³⁰ in which the field emission processes were investigated at high pressures, of the order of 10^{-4} Torr, gave no evidence that the negative space charge found in field emission microscope experiments could be neutralized.

Vibrans³¹ has analyzed the temperature-field emission process itself and has shown it to be unstable. He points out that the field emission current increases the temperature at the surface of the projection through ohmic heating, and this increase in the temperature increases the current through thermal emission processes. The process so envisioned is unstable, leading to a rapid buildup of the current. However, Vibrans did not take into consideration cooling from the Nottingham effect³² which will tend to stabilize the temperature of the surface to a value dependent solely on the field. Experiment also

argues against the phenomenon since field emission has been shown to be stable and reproducible up to the point of breakdown. At these high fields the current does not depend strongly on temperature. However, there may be cases in which the Vibrans model can be shown to dominate over the cooling effects of the Nottingham process. An example is the case of long whiskers in which sufficient ohmic heating can occur at low fields to overcome the Nottingham effect.

A Suggested Transition Mechanism

An alternative mechanism for the initiatory event has been suggested by Alpert, Lee, Lyman and Tomaschke¹ in which the field emission currents heat the projection up to a temperature, perhaps the melting temperature, where the mechanical strength of the projection fails. They postulate that the projection then becomes strongly unstable and the electrode material begins to move into the gap under the action of the strong electrical forces. This process could either greatly enhance the electric field at the surface or increase the emitting area, or both, resulting in a large increase in the field currents. It is suggested that this process can lead to a situation closely paralleling the exploding wire experiments of Tucker.³³ In these experiments current densities comparable to those obtained in field emission experiments melt and vaporize the wire in a nanosecond's time. If in an analogous manner the projection melts and vaporizes, then it is seen that conditions are established that are ideally suited for the transition to a low-voltage, high-current arc.

This mechanism is consistent with the experimental breakdown results obtained from field emission microscope studies with tungsten cathodes. Mechanical failure at the melting point is a reasonable assumption for tungsten, since breakdown fields for tungsten are substantially less than the field strengths of 6×10^8 v/cm necessary for the rupture of the point anodes of field-ion microscopes.³⁴

The Calculation of the Critical Field for Tungsten

It remains to reconcile the experimental fact that breakdown occurs at a more or less constant electrical field with the proposed melting mechanism for electrical breakdown. At first glance, it would seem to follow that if breakdown occurs at constant field then all of the projections on the cathode surface should look more or less alike; a conclusion directly refuted by our experiments. To investigate this seemingly contradictory conclusion we have analyzed this proposed mechanism for electrical breakdown by conducting a computer analysis to determine the field necessary to bring idealized projection shapes to a critical temperature. It is shown that for a vast variety of emitter sizes and shapes, roughly corresponding to those experimentally observed, electrical breakdown will occur by the proposed mechanism for electric fields in a range within the experimental error associated with the experiments summarized in Figure 1.

In the course of carrying out these calculations, several more accurate approximations for the field-temperature dependent electron emission were found in the literature. Numerical calculations

based on these new approximations have not previously been made. Supplementary calculations representing small corrections to field-temperature emission and the Nottingham critical temperature are also given.

It is recognized that the melting of the projection is principally due to the field emission currents. Before we calculate the critical field necessary to melt the projections, we will briefly review both the field emission theory and the Nottingham effect.

A. Combined Temperature and Field Dependent Emission.

Field emission was recognized by Fowler and Nordheim³⁵ as a quantum mechanical problem in which the electrons of the conduction band are pictured as tunnelling through the field reduced potential barrier of the metal as can be seen in Figure 2. Fowler and Nordheim, using the energy distribution of the electrons within the conduction band as a function of temperature found by Sommerfield, calculated the rate of arrival of electrons at the boundary. Upon calculating the transparency of the boundary as a function of energy, they found that by taking the low temperature limit they could obtain in closed form the field-dependent current density. Fowler and Nordheim combined as a final result the following expression for the dependence of current density J on electric field:³⁶

$$J = [1.54 \times 10^{-6} E^2 / \phi t^2(y)] \cdot \exp - 6.83 \times 10^7 (\phi^{3/2} / E(y)) \quad (1)$$

where E is the electric field at the cathode surface, ϕ is the work function of the cathode material, and v and t are slowly varying

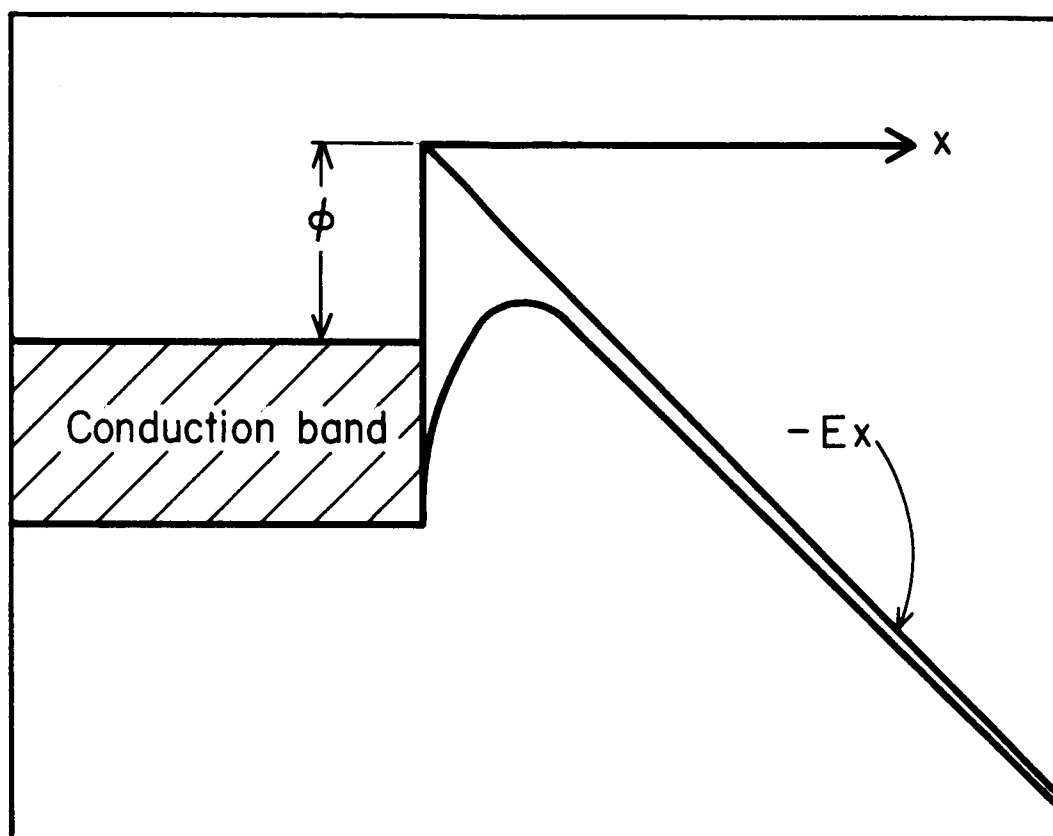


Figure 2. Schematic Diagram of Field Emission. The conduction electrons are pictured as tunneling through the field-reduced potential barrier.

functions of the variable $y = (s \cdot 79 \times 10^{-4} E^{\frac{1}{2}}) / \phi$, which are almost constant over the useful range of measurements of the current density.

Temperature corrections to field emission have been made by Dyke,³⁷ Brodie,³⁸ and Gorkov, Elinson and Yakovleva.³⁹ However, the validity of these corrections is in some question at temperatures and fields where significant electron populations exist at energy levels near and above the height of the field reduced potential barrier. At these energy levels their approximations for the transparency of the barrier give unity probability for emission which in essence treats the electron as a classical particle.

Murphy and Good,⁴⁰ using a more general form for the transparency of the barrier as a function of electron energy, found by Kemble,⁴¹ have derived expressions for the combined temperature-field emission more accurate at all temperatures and fields. In particular, Murphy and Good have shown that their expressions give as limiting cases field emission and thermal emission.

It is not the intention herein to give complete derivations of the particular results since the reader for himself may consult the references for this, but rather to give those results necessary to calculate the combined temperature-field emission. The energy distribution of the electrons in the metal is such that $N(w)$ electrons per second in the energy range dw arrive at the boundary of the metal. Fowler and Nordheim formulate $N(w)$ as follows:

$$N(w) = \frac{4\pi mkT}{3h} \log \left(1 + \exp - \frac{w + \phi}{kT} \right)$$

where m is the mass of the electron,
 k is the Boltzmann constant,
 T is the temperature in $^{\circ}\text{K}$,
 h is Planck's constant,
 ϕ is the work function.

Now the probability $D(w)$ that an electron penetrates the field-reduced barrier a and escapes as formulated by Murphy and Good is:

$$D(w) = \frac{1}{1 + \exp \frac{4\sqrt{2mw^3}}{3heF} v(y)}$$

where \hbar is $h/w\pi$,
 F is the electric field,
 $v(y)$ is a function of the complete Elliptic Integrals.

$$y = \sqrt{e^3 F / |w|}$$

for $0 < y < 1.0$.

$$v(y) = (1+y)^{\frac{1}{2}} E[(1-y)^{\frac{1}{2}} / (1+y)^{\frac{1}{2}}] - yK[(1-y)^{\frac{1}{2}} / (1+y)^{\frac{1}{2}}]$$

for $y > 1.0$.

$$v(y) = -(y/2)^{\frac{1}{2}} - 2E[(y-1)^{\frac{1}{2}} / (2y)^{\frac{1}{2}}] + (y+1)K[(y-1)^{\frac{1}{2}} / (2y)^{\frac{1}{2}}]$$

where $K(k)$ and $E(k)$ are the complete Elliptic Integrals of the first and second kind, respectively.

The current density for a particular temperature and field is found by numerically integrating the product of $N(w)$ and $D(w)$ over the energy range within the metal:

$$j = e \int_{-\infty}^0 D(w) N(w) dw$$

where

j is the current density,
 e is the electronic charge,
 w is the energy of the incident electron,
 $D(w)$ is the transmission coefficient,
 $N(w)$ is the flux of electrons incident to the surface.

The results of the calculations are given in Figure 3, where the common logarithm of the current density is given as a function of both the electric field and the temperature.

B. The Nottingham Effect

One of the fundamental assumptions of the field emission calculation is that the electron distribution within the metal is the steady-state distribution found by using Fermi-Dirac statistics. This is a reasonable assumption since even at the highest current densities found experimentally only a small percentage of the electrons in the metal which strike the barrier also penetrate it. Nottingham³² recognized that when the emitted electrons are replaced in the distribution within the metal an energy exchange process develops between the crystal lattice and the electron distribution. Postulating that this electron must come from the Fermi level, Nottingham predicted that the emission current may either heat or cool the surface depending on whether the majority of the emitted electrons

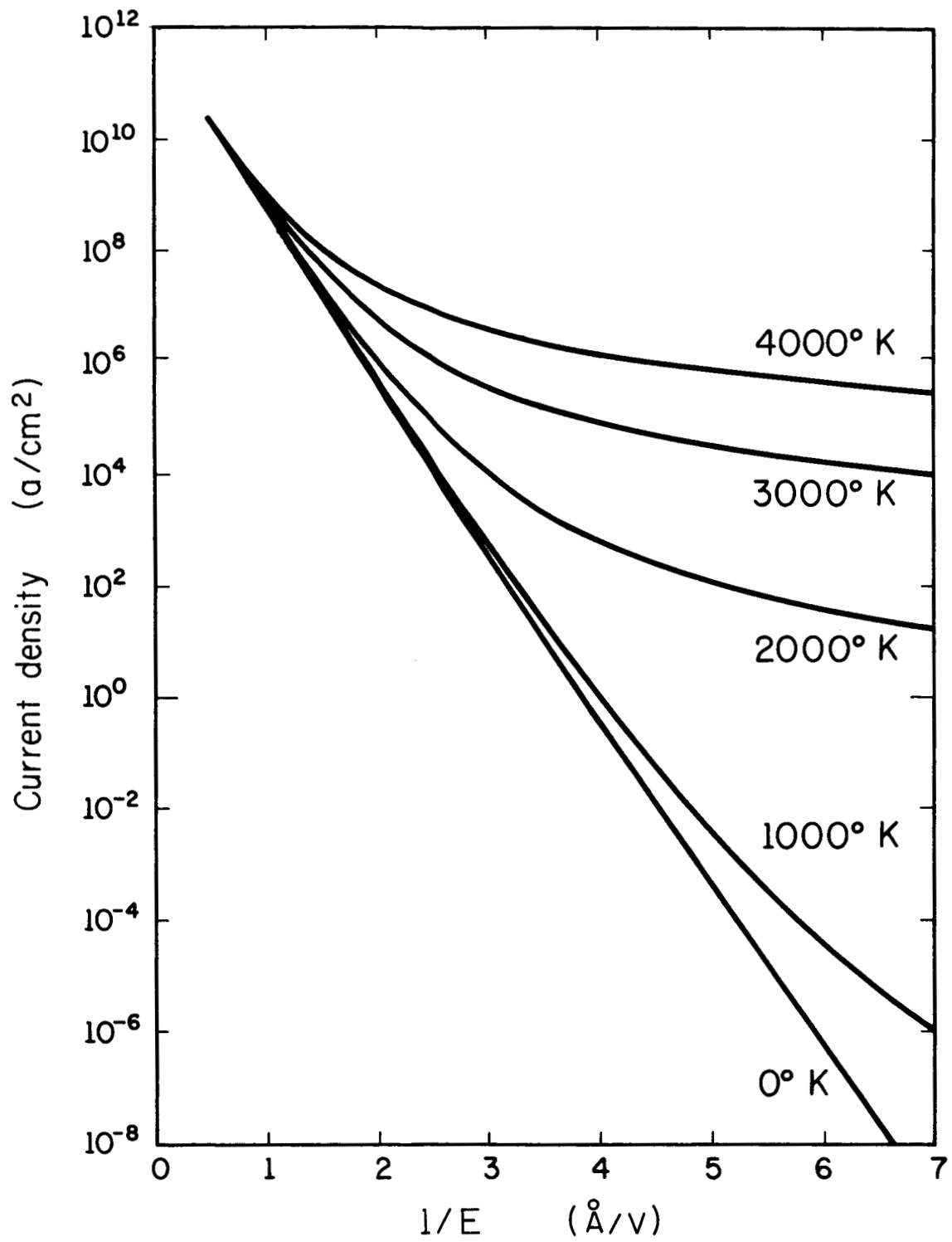


Figure 3. Field Emission Current Density as a Function of Field and Temperature.

come from below the Fermi level or from above it. Thus if the emitted electron comes from below the Fermi level, the electron from the Fermi level used to fill this vacancy gives up energy to the lattice leading to Nottingham heating. Alternatively when the electron is emitted from above the Fermi level, the lattice must supply the energy necessary to excite an electron from the Fermi level to replace the emitted electron, thus leading to Nottingham cooling of the surface.

These effects can clearly be seen in the interpretation of the normalized current densities in Figures 4 and 5. Here the emitted electron energy distributions are plotted. They are obtained by evaluating at a given temperature and field the product of the transparency of the barrier $D(w)$ and the rate of arrival $N(w)$ used in the last section to determine the current density. Although the actual current densities differ by orders of magnitude it is only the symmetry with respect to the Fermi level which will determine whether the Nottingham effect will be heating or cooling. The magnitude of the effect nevertheless will depend on the magnitude of the current density.

Consider Figure 4 in which three different electron distributions for the same temperature but differing fields are shown. It will be seen that as the field is increased the number of electrons penetrating the barrier below the Fermi level is increased. Alternatively, as can be seen in Figure 5, increasing the temperature increases the number of electrons in the energy levels above the Fermi level, thus shifting the distribution toward higher energy levels.

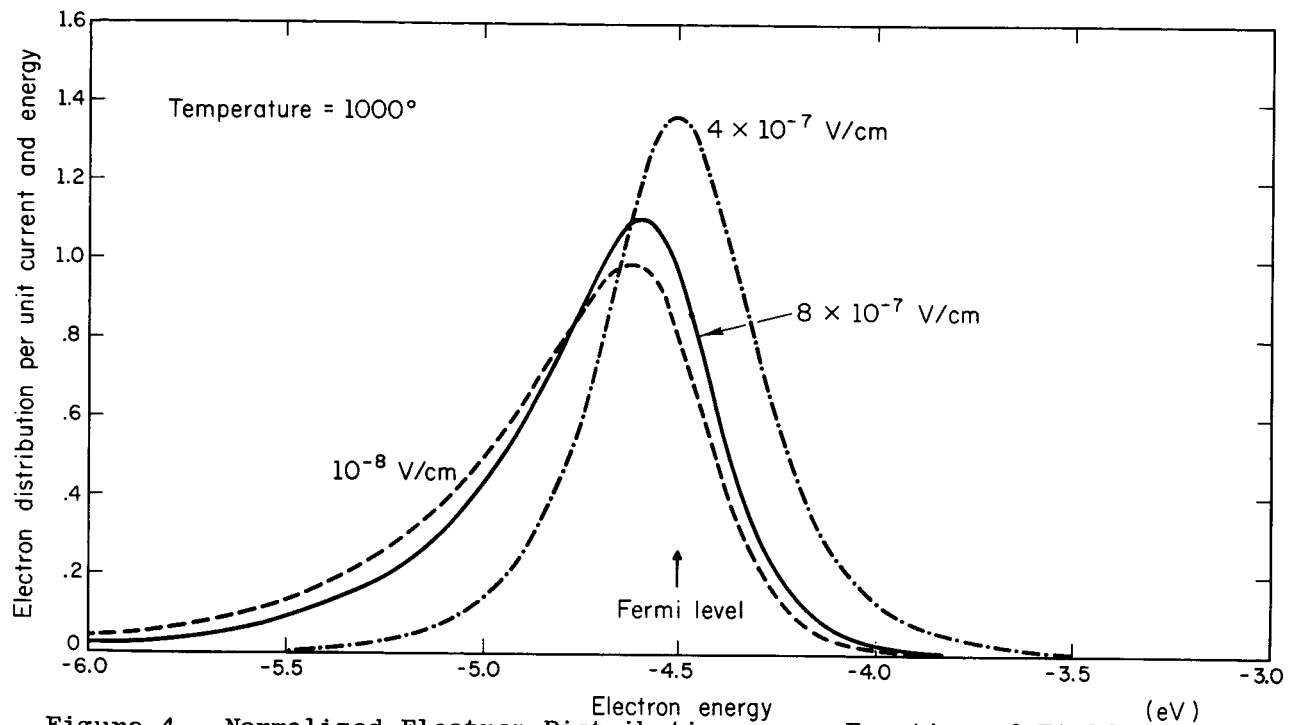


Figure 4. Normalized Electron Distributions as a Function of Field at Constant Temperature. The curves are normalized to equal areas.

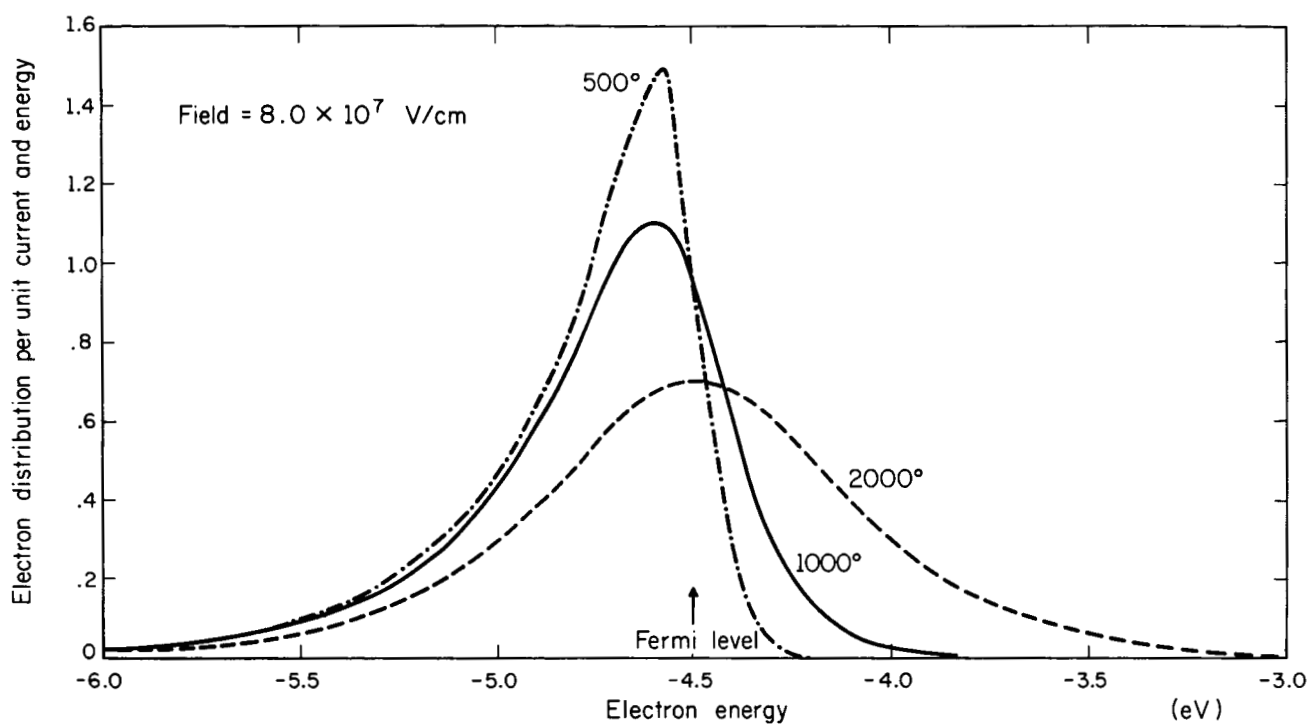


Figure 5. Normalized Electron Distributions as a Function of Temperature at Constant Field.

It was recognized by I. Brodie³⁸ that if the other sources of heating and cooling could be ignored, the Nottingham effect would stabilize the temperature of the emitting surface to a temperature which was solely dependent on the electric field. At this temperature, called the critical temperature by Levine,⁴² the energy which the lattice supplied for the electrons emitted above the Fermi level is exactly equal to the energy received by the lattice for electrons emitted below the Fermi level. Thus if the temperature of the surface is below the critical temperature more electrons are emitted below the Fermi level than above, giving rise to Nottingham heating, which will tend to bring the temperature of the surface to the critical temperature. Increasing the electric field increases the number of electrons emitted below the Fermi level thus demanding that the inversion temperature increase.

The Nottingham effect can be formulated as follows:

$$NT = e \int_{-\infty}^0 \int_{-\infty}^E (w+\phi) D(w) N(E,w) dE dw$$

where the functions $D(w)$ and $N(w)$ have the same significance as in the current density calculation. However, account must be taken of the fact that the original electron distributions found by Fowler and Nordheim were distributions of normal energy of the electron with respect to the barrier. Young⁴³ has considered this and has reformulated the supply function as a function of both total energy and of the normal energy component of the total energy as:

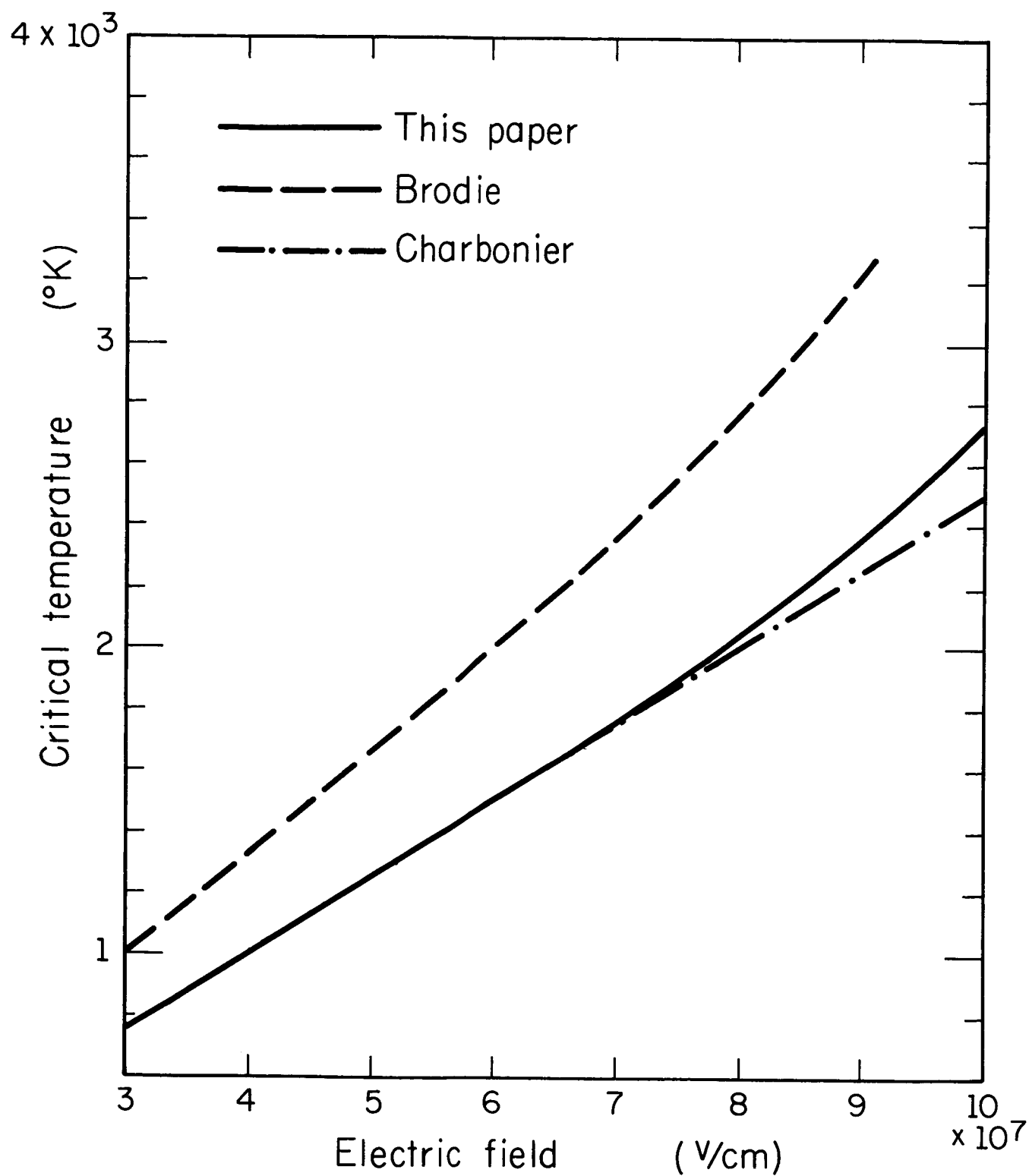


Figure 6. The Critical Temperature as a Function of the Field.

temperature distribution must be fitted. The assumption that the Nottingham effect is solely a surface effect demands that the transfer of energy to and from the metal lattice occur very near the surface. There is no experimental justification for this assumption. Indeed the energy transfer may occur deep within the metal by a multiple step transition process. If this were the situation then the effects of the Nottingham process on the temperature of the surface and on the temperature distribution in the projection would be greatly exaggerated. However, in the absence of direct experimental evidence in regard to this point we make the assumption that the process occurs at the surface allowing us to include the Nottingham effect as a boundary condition rather than as a more mathematically cumbersome volume heating or cooling effect.

It should be noted that calculation of the critical temperature is not dependent on where the energy transfer takes place but is only a function of the field at the surface and the electron. The steady state heat conduction equation:⁴⁴

$$K \nabla^2 T = -g(x,y,z)$$

where $g(x,y,z)$ is the source function.

For radial symmetry in a spherical coordinate system and for the case of resistive heating the conduction equation reduces to a second order differential equation as follows:

$$\frac{1}{r^2} \frac{d}{dr} \left(r^2 \frac{dT}{dr} \right) = - \frac{\rho}{K} j^2(r)$$

where ρ is the resistivity of the medium and K , the thermal conductivity. If we let j_o be the field emission current density at the emission surface and r_o the location of the emission surface then the differential equation assumes the final form:

$$\frac{1}{r^2} \frac{d}{dr} \left(r^2 \frac{dT}{dr} \right) = - \frac{\rho}{K} j_o^2 \left(\frac{r_o}{r} \right)^4 .$$

It should be noted that the equation may be solved analytically for the case in which the resistivity and the thermal conduction are not functions of the temperature. However, in the range of interest here the resistivity varies by a factor of nearly twenty and the equation must be solved by numerical means.

The numerical solution is found by stipulating the temperature and the field at the emission site. The field and the temperature are sufficient to specify the Nottingham effect, and it is used to determine the initial value of the dT/dr since KdT/dr is the energy transported across the emission site by the Nottingham effect. Thus the field and the temperature at the emission site are used for adjustable parameters in the calculation to find appropriate solutions which have as a maximum temperature the melting point of tungsten and room temperature at the cold end of the projection.

Numerical Methods

The numerical integration of the heat equation as well as the temperature-field emission and the Nottingham effects was accomplished using the methods developed by A. Nordsieck.⁴⁵ In this

method the integration step size is controlled by the integration routine to assure convergence to a solution as well as to control the integrated error.

The error sizes were chosen so as to assure at least four significant figures. In this calculation, the resistivity and the heat conduction were both considered functions of the temperature. The approximations used were found by the methods presented by Hastings.⁴⁶ In particular, the experimental data of Langmuir⁴⁷ were fitted to a third order polynomial to achieve a nearly Chebyshev error of $\pm .2$ ohms/cm over the range from 300°C to the melting temperature of tungsten. Experimental values of the thermal conductivity are not available over this entire range. Thus recourse had to be made to the Wiedemann-Franz Ratio⁴⁸ to approximate the thermal conductivity. A ratio of two third-order polynomials was chosen to fit the available data of Langmuir⁴⁹ and Holliday and Worthington.⁵⁰ The high temperature values were determined by the requirement that the high temperature limit ratio approach the theoretical value⁴⁸ of

$$\frac{\pi^2}{3} \frac{k^2}{2} = 2.45 \times 10^{-8} .$$

The errors in the approximation for the coefficient of heat conduction when compared to the experimental values were random in nature. The formulations for the resistivity, ρ , and thermal conductivity, K , used in the calculations are:

$$10^6 \rho = -1.8851 + 23.6572T/(10^3) + 3.2696T^2/(10^6) - .2325T^3/(10^9) .$$

$$K(T) = \frac{TL(T)}{\rho}$$

where $L(T) =$

$$\frac{3.92108 - 2.16520T/(10^3) - 1.79225T^2/(10^6) + 2.45T^3/(10^9)}{1.17466 - .18169T/(10^3) + 1.15563T^2/(10^6) + T^3/(10^9)} \times 10 .$$

Finally, the complete elliptical integrals were evaluated using Hastings',⁴⁶ formulation which gives about six decimal places of accuracy.

Results of the Calculation

The results of the calculations of the temperature distributions are summarized in Figures 7 and 8. In Figure 7 is shown the critical field as a function of the length and cone angle. The critical field is the field for which some portion of the projection will be near the melting point. Notice that the actual length of the whisker does not become important until the cone angle becomes very small. For conical projections the important parameter is the emitting area.

In Figure 8 we present the temperature distributions along one micron length projections of various cone angles. Notice that at small cone angles the distribution is approximately parabolic as is the case for cylindrical projections. However, as the cone angle is increased, the distribution becomes a nearly $1/r^2$ law.

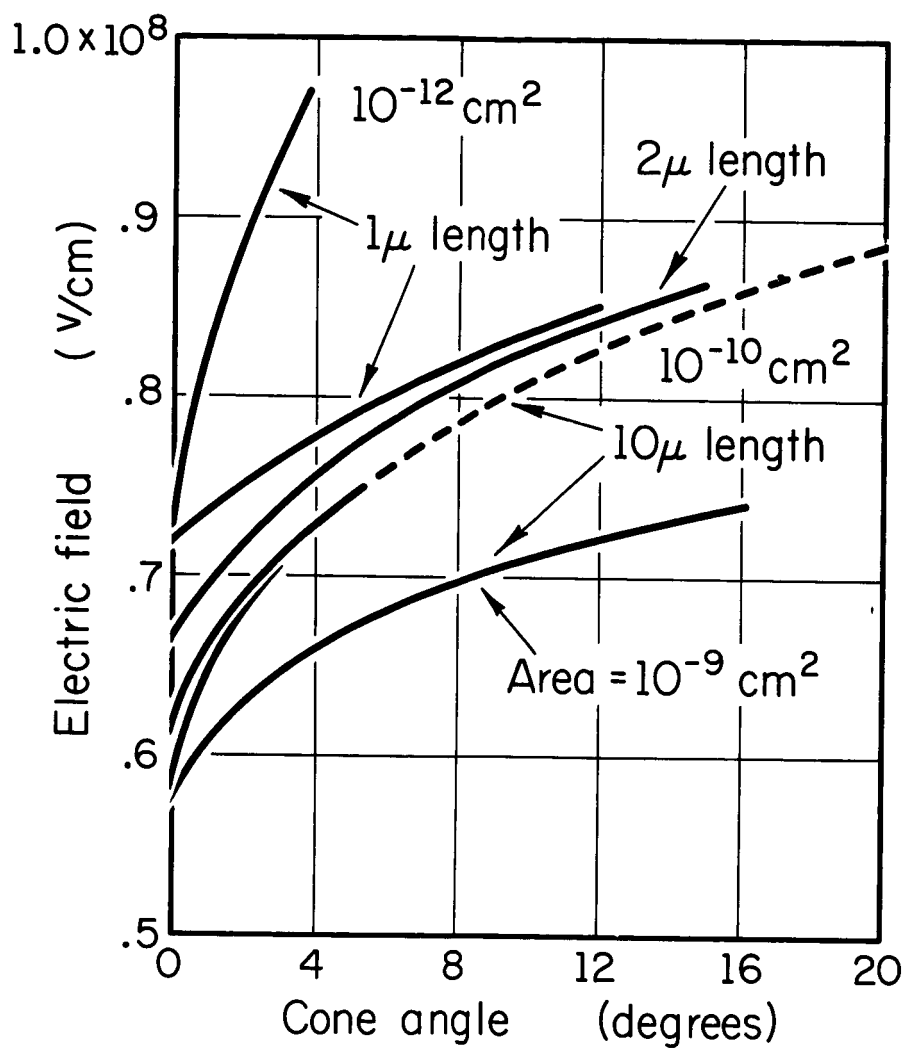


Figure 7. The Critical Field as a Function of the Length and Cone Angle.

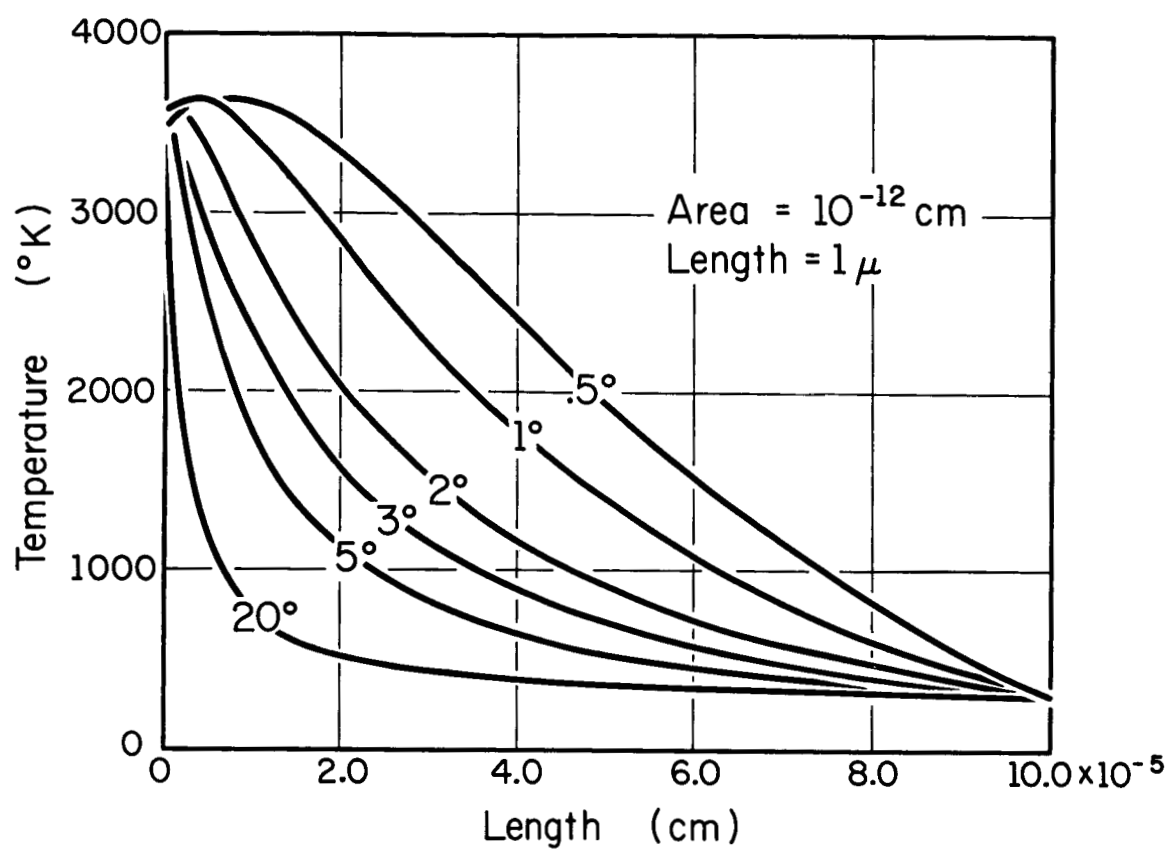


Figure 8. Temperature Distribution along One Micron Length Projections as a Function of Various Cone Angles. All the cases are situations in which the maximum temperature is equal to the melting temperature.

It is interesting to note that the average breakdown field gives a critical length for a cylinder of roughly 2 microns, a length which is consistent with our experimental findings and with those of Little and Whitney.¹⁴ From the conical results we note that if breakdown proceeds via the proposed mechanism, it must be associated with projections of small cone angle.

Concluding Discussion

The results of the calculations clearly indicate the plausibility of the theory that breakdown occurs at or near the field necessary to bring the temperature of the projection to the melting point of tungsten. The curves also indicate the reason for describing electrical breakdown as a field phenomenon. Since the experimental error of the observations, $\pm 1 \times 10^7$ v/cm, encompasses nearly two orders of magnitude of critical length in the cylindrical case, then minor variations in emitter geometry would require only insignificant changes in the field to achieve breakdown.

This fantastic variation of the critical length with electric field is a direct consequence of the equally fantastic variation of current with field. In Figure 9 we plot current density versus electric field for three different work functions. It can be seen that for all substances, an increase of field at one order of magnitude from 10^7 to 10^8 volts/cm gives rise to as much as 20 orders of magnitude increase in current density. It is therefore not surprising

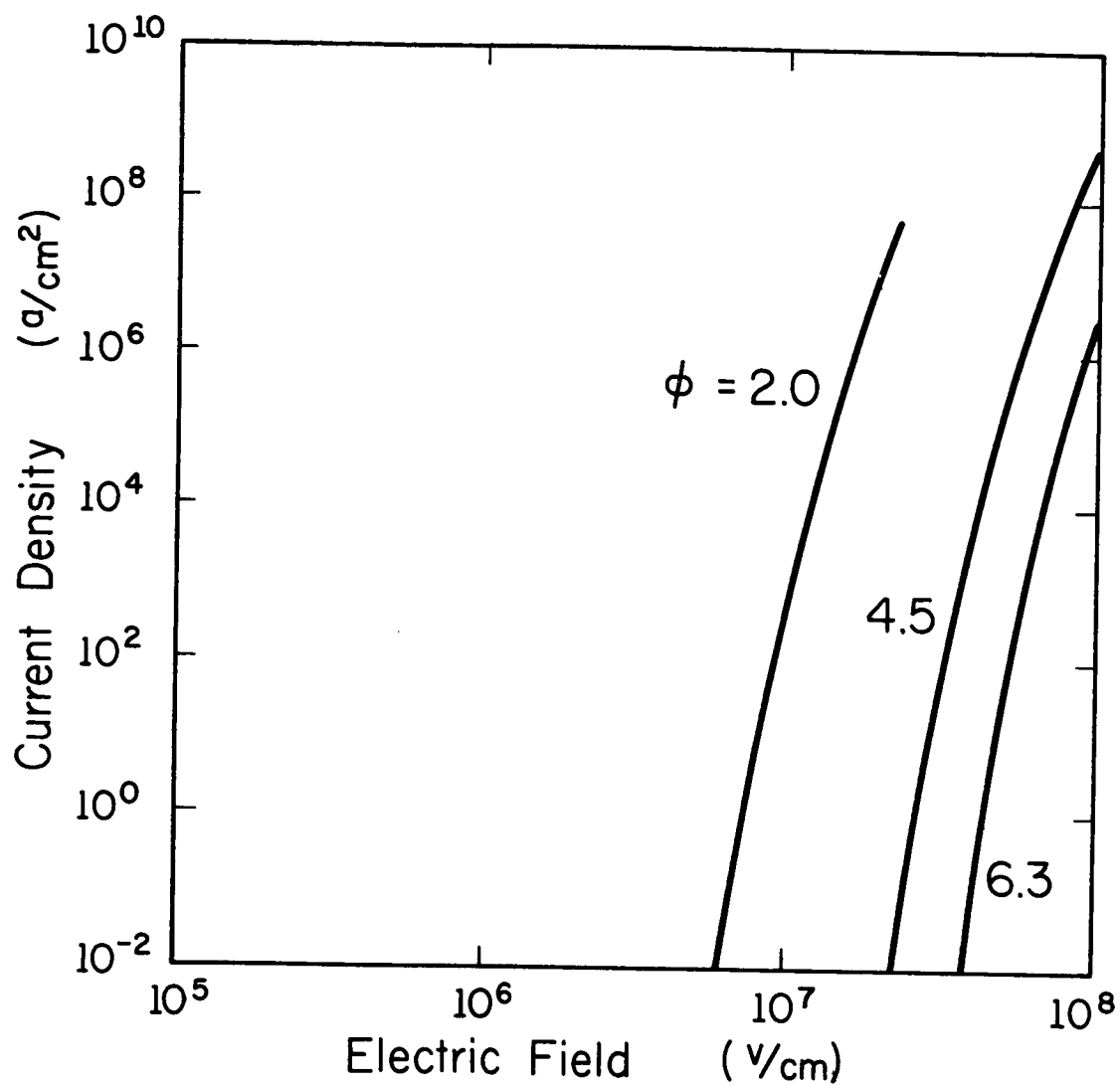


Figure 9. Fowler-Nordheim Current Density as a Function of Electric Field. Notice that one order of magnitude change in electric field produces more than fourteen orders of magnitude change in current density.

to expect something violent to occur when one runs into this brick wall of field emission.

We suggest that electrical breakdown in vacuum is a process in which a projection on the cathode surface is heated until the electrode becomes mechanically unstable and the weakened material is drawn into the electrode gap under the influence of the strong electric fields. In this circumstance the field emission current will be further enhanced since the field will be rapidly increasing due to the changing geometry. The enhanced current then allows for more heating of the material leading to further current buildup. The field emission process then presents a self-consistent picture of electrical breakdown in which no recourse is made to the use of adjustable parameters to fit experiment to theory.

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